

SECTION C — CHEMISTRY; METALLURGY

C25 ELECTROLYTIC OR ELECTROPHORETIC PROCESSES; APPARATUS THEREFOR

C25F PROCESSES FOR THE ELECTROLYTIC REMOVAL OF MATERIALS FROM OBJECTS; APPARATUS THEREFOR (treatment of water, waste water or sewage by electrochemical methods C02F 1/46; anodic or cathodic protection C23F) [2]

Note(s)

In this subclass, in the absence of an indication to the contrary, classification is made in the last appropriate place.

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| 1/00 | Electrolytic cleaning, degreasing, pickling, or descaling [2] | 3/12 | • • of semiconducting materials [2] |
| 1/02 | • Pickling; Descaling [2] | 3/14 | • • locally [2] |
| 1/04 | • • in solution [2] | 3/16 | • Polishing [2] |
| 1/06 | • • • of iron or steel [2] | 3/18 | • • of light metals [2] |
| 1/08 | • • • of refractory metals [2] | 3/20 | • • • of aluminium [2] |
| 1/10 | • • • of actinides [2] | 3/22 | • • of heavy metals [2] |
| 1/12 | • • in melts [2] | 3/24 | • • • of iron or steel [2] |
| 1/14 | • • • of iron or steel [2] | 3/26 | • • • of refractory metals [2] |
| 1/16 | • • • of refractory metals [2] | 3/28 | • • • of actinides [2] |
| 1/18 | • • • of actinides [2] | 3/30 | • • of semiconducting materials [2] |
| 3/00 | Electrolytic etching or polishing [2] | 5/00 | Electrolytic stripping of metallic layers or coatings [2] |
| 3/02 | • Etching [2] | 7/00 | Constructional parts, or assemblies thereof, of cells for electrolytic removal of material from objects (for both electrolytic coating and removal C25D); Servicing or operating [2] |
| 3/04 | • • of light metals [2] | 7/02 | • Regeneration of process liquids [2] |
| 3/06 | • • of iron or steel [2] | | |
| 3/08 | • • of refractory metals [2] | | |
| 3/10 | • • of actinides [2] | | |